I hereby certify that this correspondence is being deposited with the United States Postal Service as First Class Mail in an envelope addressed to: Commissioner for Patents, Alexandria, VA 22313-1450.

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In Re Application of :

February 12, 2004

Liebmann et al.

Serial No. 10/708,055

Examiner:

Filed: 02-05-04

IBM Corporation Dept. 18G/Bldg. 300-482

Title: METHOD OF CONFLICT AVOIDANCE

2070 Route 52 Hopewell Junction, New York 12533-6531

IN FABRICATION OF GATE-SHRINK ALTERNATING PHASE SHIFTING MASKS :

INFORMATION DISCLOSURE STATEMENT

Commissioner for Patents P. O. Box 1450 Alexandria, VA 22313-1450

Sir:

In compliance with the duty of disclosure under 37 C.F.R. § 1.56 and in accordance with the practice under 37 C.F.R. §§ 1.97 and 1.98, the Examiner's attention is directed to the documents listed on the enclosed Form PTO-1449. Copies of the listed documents are also enclosed.

It is respectfully requested that the above information be considered by the Examiner and that a copy of the enclosed Form PTO-1449 be returned indicating that such information has been considered.

Applicants undersigned attorney may be reached by telephone

at (845) 894-6919. All correspondence should continue to be directed to the below listed address.

Respectfully submitted,

Todd M. C. Li

Attorney for Applicants Registration No.45,554

INTERNATIONAL BUSINESS MACHINES CORPORATION Intellectual Property Law Department B/300-482 2070 Route 52 Hopewell Junction, New York 12533 Facsimile: (845) 892-6363

TML/kcm

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FORM PTO-1449 (Modified)		U.S. DEPARTMENT OF COMMERCE PATENT AND TRADEMARK OFFICE			AT PACKET O.: FIS920030379US1			IAL NO.: /708,055			
SUPPLEMENTAL INFORMATION DISCLOSURE STATEMENT BY APPLICANT					APPLICANT: Lars W. Liebmann et al.						
(Use several sheets if necessary) (37 CFR 1.98(b))					FILING DATE: 02-05-04			GROUP:			
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EXAMINER: Initial if reference considered, whether or not citation is in conformance with MPEP 609. Draw line through citation if not in conformance and not considered. Include copy of this form with next communication to applicant. ibmf100417000ids2